

AIXTRON is a leading provider of deposition equipment to the semiconductor industry. The Company's technology solutions are used by a diverse range of customers worldwide to build advanced components for electronic and opto-electronic applications based on compound semiconductor materials as well as carbon nanotubes (CNT) and other 2D nanomaterials. Such components are used in fiber optic communication systems, wireless and mobile telephony applications, optical and electronic storage devices, computing, signaling and lighting, as well as a range of other leading-edge technologies.

AIXTRON's product portfolio includes:

- MOCVD Equipment based on the Planetary Reactor® or Close Coupled Showerhead® concept for compound semiconductor materials.
- Warm-Wall CVD systems for high-temperature SiC applications and research systems.
- MOCVD, CVD and Plasma Enhanced CVD systems for the deposition of carbon nanotubes and nanofibers.

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